# EAST Search History

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|---|---|---|---|---|---|---|
| L3 | 4 | "634458".ap. | US-PGPUB; USPAT | OR | ON | 2006/05/27 13:56 |
| L4 | 181 | "134"/$.ccls. and (wafer or semiconductor or substrate or workpiece) near10 (clean$3 or wash$3) same (supercritical) and (mixer or mix$3 or stir or combin$3) | US-PGPUB; USPAT | OR | ON | 2006/05/27 14:48 |
| L5 | 164 | "134"/$.ccls. and (wafer or semiconductor or substrate or workpiece) near10 (clean$3 or wash$3) same (supercritical) and (mixer or mix$3 or stir or combin$3) and heat$3 | US-PGPUB; USPAT | OR | ON | 2006/05/27 14:53 |

C:\Documents and Settings\shusband\My Documents\EAST\Workspaces\10634458 Wafer process system.wsp